

ERRATUM

Erratum: “Morphology of TiSi_2 and ZrSi_2 on Si(100) and (111) surfaces” [J. Mater. Res. **9**, 1214–1227 (1994)]

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After this article appeared in the May issue of *Journal of Materials Research*, the authors noticed an error in Eq. (2) on page 1217. In Eq. (2) on that page, the second equal sign is incorrect and should have appeared as a plus sign.

The corrected equation is printed below.

$$\sigma_{\text{Si}} = \sigma_{\text{film}} + \sigma_{\text{interface}} \quad (2)$$